



Docket No.: OMY-0034
(PATENT)

TPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Masatoshi SHIRAI SHI et al.

Application No.: 10/735,926

Confirmation No.: 4251

Filed: December 16, 2003

Art Unit: 1756

For: **SUBSTRATE PROCESSING METHOD AND
SUBSTRATE PROCESSING APPARATUS**

Examiner: Chacko Davis, Daborah

RESPONSE TO RESTRICTION REQUIREMENT

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

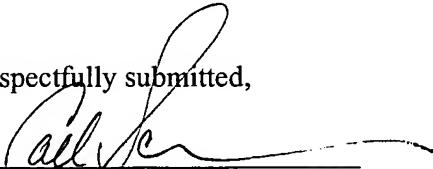
In response to the Restriction Requirement dated September 7, 2006, Applicant hereby provisionally elects, without traverse, Group I, claim 1-21, for continued examination.

Please note that Applicant reserves the right to file divisional applications covering the subject matter of the non-elected claims.

Applicant believes no fee is due with this response. However, if a fee is due, please charge our Deposit Account No. 18-0013, under Order No. OMY-0034 from which the undersigned is authorized to draw.

Dated: September 21, 2006

Respectfully submitted,

By 
Carl Schadkowitch

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